Substitute for form PTO/SB/08A  INFORMATION DISCLOSURE STATEMENT BY APPLICANT		Complete if Known		
		Application Number	09/940,141	
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		First Named Inventor	Douglas Cheline	
		Art Unit	2444	
		Examiner Name	SHAW, Peling Andy	
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U.S. PATENT DOCUMENTS						
Examiner Initials*	Cite No.	Document Number  Number-Kind Code	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appea	
		US-2003/0009592	01-2003	Stahura, Paul		
		US-2004/0039798	02-2004	Hotz et al.		
		US-5,777,989	07-1998	McGarvey, John Ryan		
		US-6,871,347	03-2005	Hay, Russell C.		
		US-2002/0027915	03-2002	Foti et al.		
		US-6,560,634	05-2003	Broadhurst, Larry Joe		
- "		US-6,118,768	09-2000	Bhatia et al.		
		US-6,108,330	08-2000	Bhatia et al.		
•		US-2003/0039268	02-2003	Chong et al.		
		US-2003/0014541	01-2003	Poeluev, Yuri		
		US-2002/0010798	01-2002	Ben-Shaul et al.		
		US-2001/0036192	11-2001	Chiles		

NON PATENT LITERATURE DOCUMENTS				
Examiner Cite Initials* No.		Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volumne-issue number(s), publisher, city and/or country where published.		
		MICROSOFT CORPORATION; Microsoft: Windows 2000 Server; Windows 2000 DNS; White Paper; October 1999; cover, table of contents, pages 1-65.		
		KANGASHARJU et al.; "A Replicated Architecture for the Domain Name System"; March 2000; INFOCOM 2000; Nineteenth Annual Joint Conference of the IEEE Computer and Communications Societies Proceedings; Vol. 2; pages 660-669.		

Examiner Signature	/m - P Ob /	Date Considered	03/05/2010

<sup>\*</sup>EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.